

IN THE CLAIMS

Please cancel claim 5 without prejudice or disclaimer of the subject matter contained therein.

Please amend the claim 1 as follows:

1. (Amended) A method of preventing generation of particles in a chamber, the method comprising:

mounting a substrate within a chamber of a gas-exposure equipment;

decreasing a pressure within the chamber;

injecting a surface treatment gas into the chamber, the surface treatment gas converting a surface of the substrate into an organic material; and

drawing out the surface treatment gas from the chamber while injecting a nitrogen gas into the chamber.